

## Nanolayered Coatings for Cryogenic Operation

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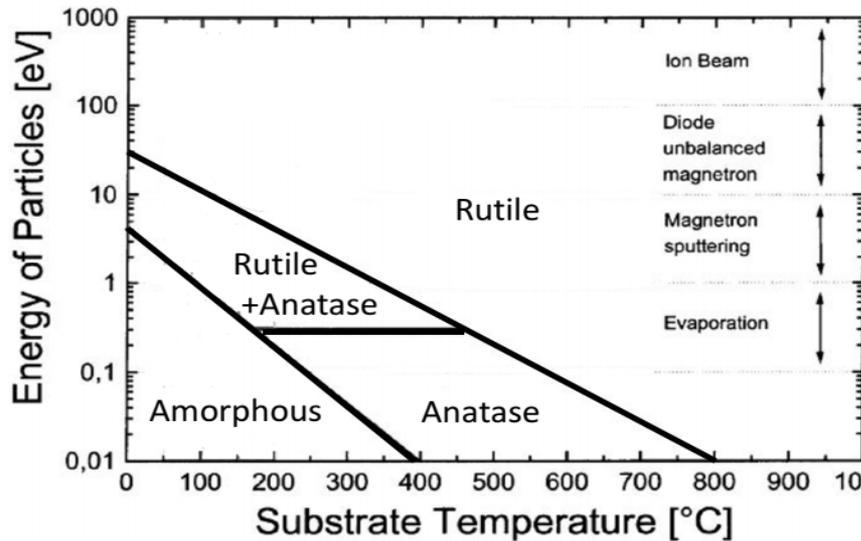


# Outlook

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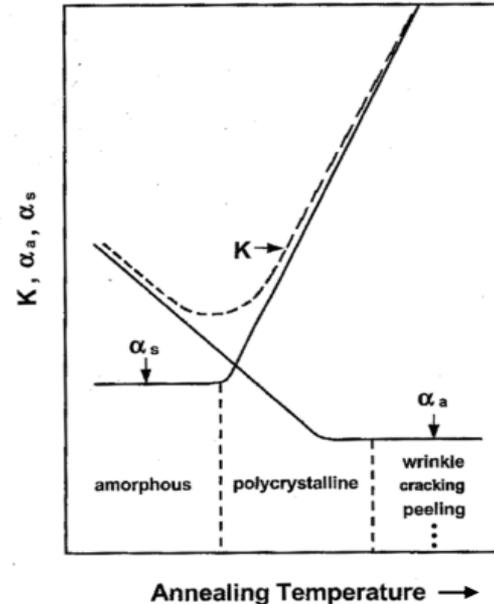
- Nanolayers: the Titania Paradigm
- Nanolayered Silica/Titania Composites
  - Suppression of Annealing-Induced Crystallization
  - Suppression of Cryogenic Loss-Peak
- Nanolayered-composite Based HR Coatings
- Feasibility
- The USannio/UniSA Labs & their VCR&D Research Program
- Candidate Materials
- Questions and Simulations
  - Nanocomposite Modeling
  - HR Coating Modeling (QWL)
- Best Nanolayered-composite Based HR Designs
- Conclusions

# The TiO<sub>2</sub> Paradigm



J. Szczyrbowski, Surf. Coat. Technol. 112 (1999) 261–266.

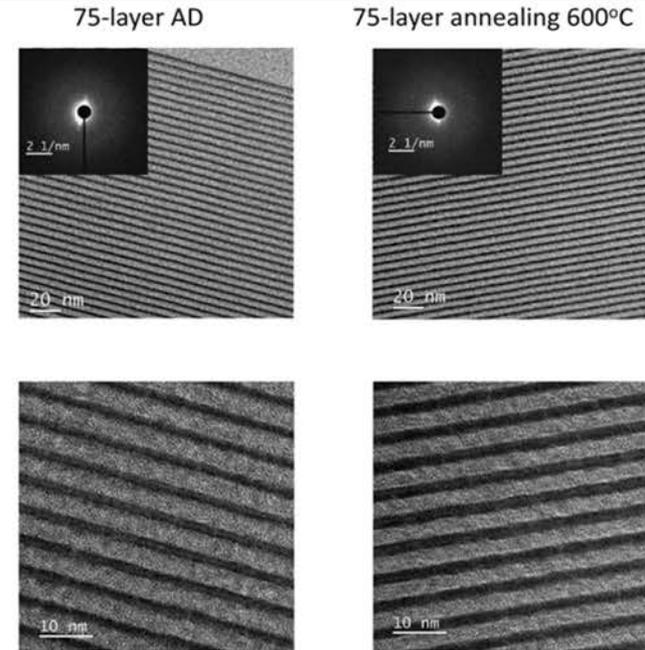
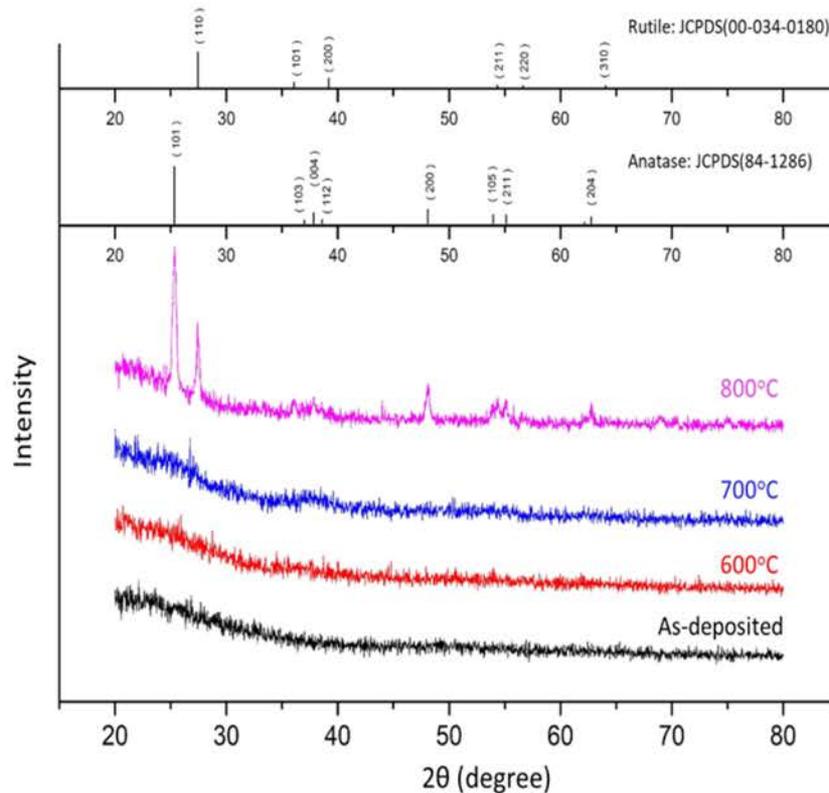
Extinction coefficient, and its absorption and scattering components, vs  $T_{\text{annealing}}$ .



W.H. Wang & S. Chao, Opt. Lett., 23 (1998) 1417

# SiO<sub>2</sub>/TiO<sub>2</sub> Nanolayered Composites

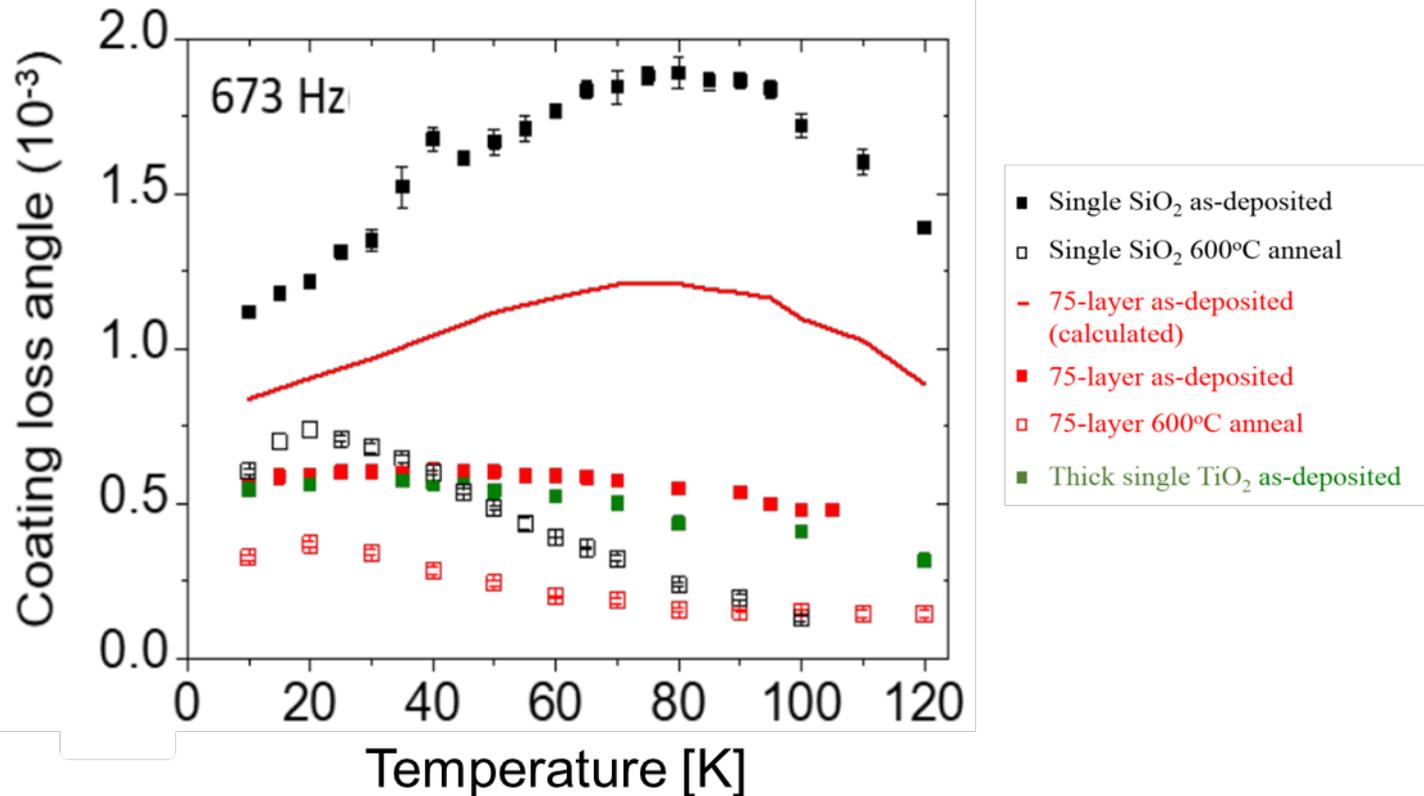
[S. Chao et al., LIGO-G1900356]



A 75 layer nanocomposite film [38 x (TiO<sub>2</sub>=1.8nm), 37 x (SiO<sub>2</sub>=3.6nm)] remains amorphous after annealing at 600C, and its morphology is preserved

# Mechanical Losses of SiO<sub>2</sub>/TiO<sub>2</sub> Nanolayers

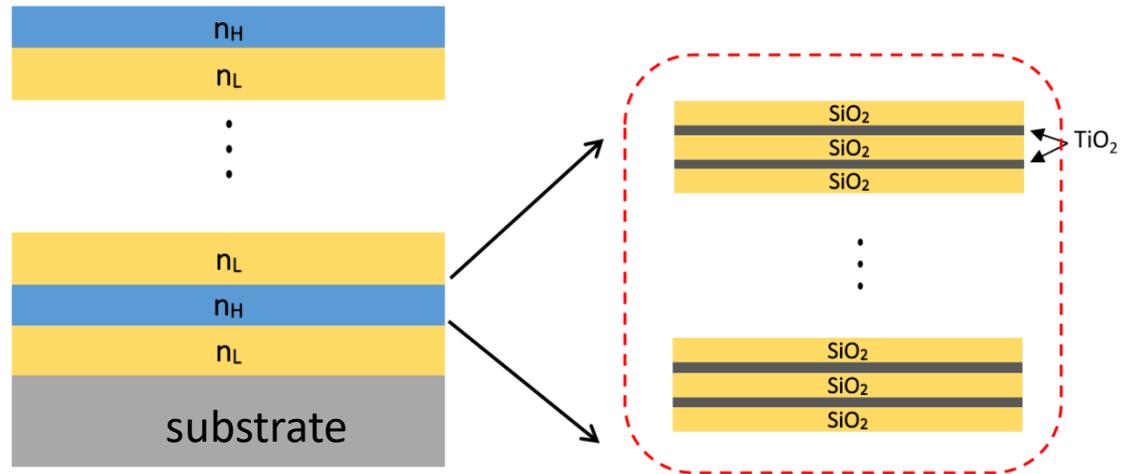
[S. Chao et al., LIGO-G1900356]



- The mechanical loss-angle of the [38 x (TiO<sub>2</sub>=1.8nm), 37 x (SiO<sub>2</sub>=3.6nm)] nanolayered film was reduced to  $\approx 1 \cdot 10^{-4}$  after 600C annealing (a factor  $\approx 9$  lower than as deposited)
- **No cryopeak is inherited from Silica.**

# Nanocomposite Based HR Coatings

Nanocomposite replacement for high-index coating layers



# Feasibility

## Nanolayers are *routinely deposited* to produce X-Ray Mirrors

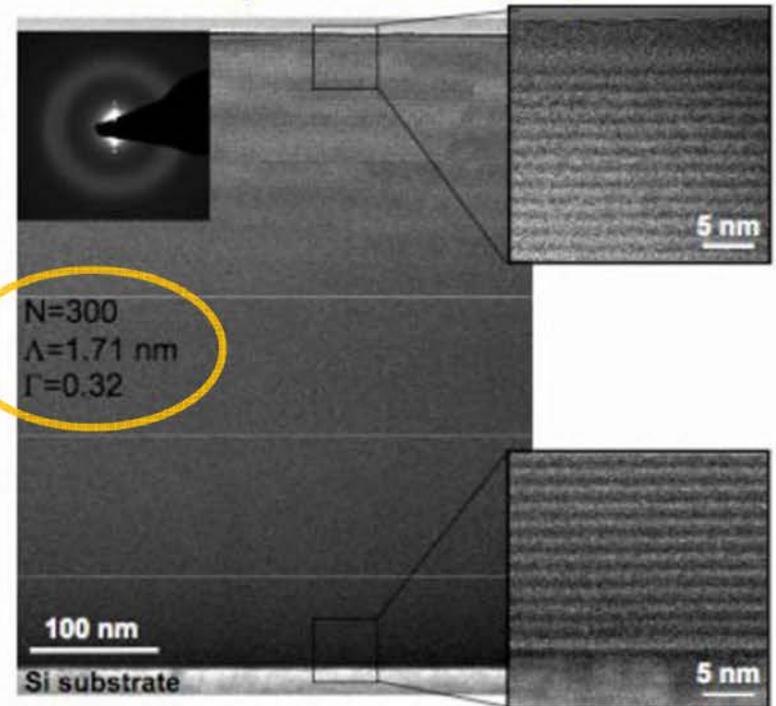
Interference mirrors consisting of hundreds/thousands of nm scale layers, with sub - nm precision [see, e.g., Proc . 10<sup>th</sup> PXRMS Conf. (2008)] , using

- Interleaved nm-scale “buffering” layers to prevent crystallization & maintain flatness [E. Gullikson, Proc. 8<sup>th</sup> PXRMS (2006)]
- Ion assisted (modulated) magnetron sputtering [N. Ghafoor et al., Thin Sol. Films 516 (2008) 982]



**Control of stress, crystallite size, and roughness** [D.L. Windt, Proc. SPIE (2007) vol 6688]

Interleaved B<sub>4</sub>C- Cr/Sc multilayer

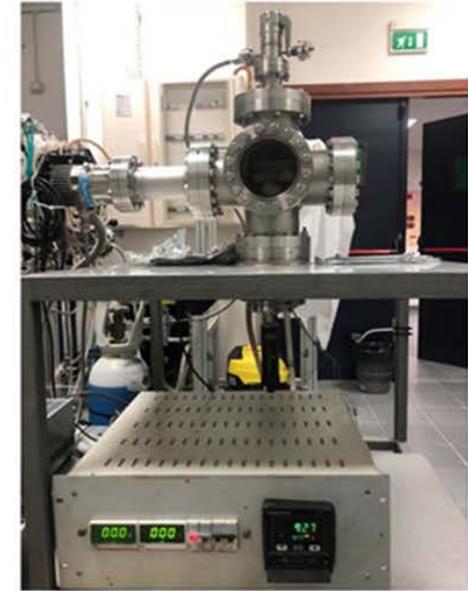


## University of Sannio Optical Film Deposition Lab



- Up to 6 co-deposited materials;
- Dual e-beam (one installed);
- Plasma IAD;
- Fully programmable deposition with GUI;
- Accuracy/repeatability at the Å level;

## UniSA-SpNM Lab

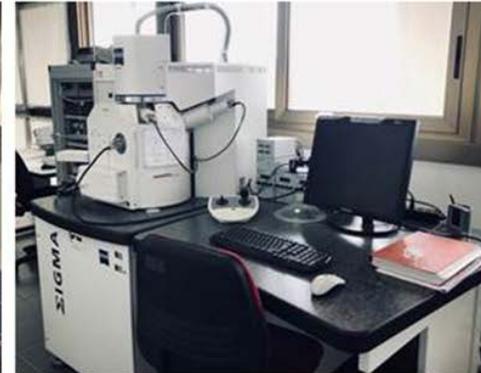


- Annealing oven
- May accommodate up to 3-inch Ø dyes;
- Max annealing temperature : 900 ° C;
- Fully programmable annealing schedule;
- PID feedback-controlled heater power supply with 0.05 ° C accuracy/stability;
- High-vacuum or controlled atmosphere (air, O<sub>2</sub>, N<sub>2</sub>, etc.)

# The USannio/UniSA Coating Labs



Dept. of Physics “E.R. Caianiello”, SpNM and CNR-SPIN Labs, University of Salerno



Left to right, top to bottom:  
FEI Tecnai 20 (TEM);  
Zeiss LEO-EVO 50 (EDS-SEM);  
Zeiss Sigma Gemini (FE-SEM);  
Renishaw Invia (Raman);  
JPK Nanowizard 3 (AFM);  
Philips 'Xpert-Pro (XRD);

# Candidate Materials

	n @ 1064nm	k @ 1064nm	Y [Gpa]	$\phi$	$\nu$
SiO <sub>2</sub>	1.4496 (1)	uncertain	72 (2)	$5.0 \cdot 10^{-5}$ (2,3)	0.17 (2)
Al <sub>2</sub> O <sub>3</sub>	1.7545 (1)	uncertain	210 (2)	$2.4 \cdot 10^{-4}$ (2)	0.22 (2)
Ta <sub>2</sub> O <sub>5</sub>	2.0760 (1)	uncertain	140 (2)	$4.72 \cdot 10^{-4}$ (3)	0.23 (2)
HfO <sub>2</sub>	2.0813 (1)	uncertain	380 (2)	$5.9 \cdot 10^{-4}$ (2)	0.2 (2)
ZrO <sub>2</sub>	2.1224 (1)	uncertain	200 (2)	$2.3 \cdot 10^{-4}$ (2)	0.27 (2)
Nb <sub>2</sub> O <sub>5</sub>	2.2537 (1)	uncertain	68 (2)	$4.6 \cdot 10^{-4}$ (2)	0.20 (2)
TiO <sub>2</sub>	2.4789 (1)	uncertain	165 (3)	$1.4 \cdot 10^{-4}$ (3)	0.28 (2)

(1) <https://refractiveindex.info/>

(2) J. Franc et al., ET-021-09 (2009), [arxiv/papers/0912/0912.0107.pdf](https://arxiv.org/abs/0912.0107); Flaminio et al., CQG 27 (2010) 083030

(3) M. Principe et al., Phys. Rev. D81 (2015) 022005, also Scott and MacKrone, Rev. Sci. Instr. 39 (1968) 821

More recent reviews of coating materials :

M. Granata et al., Phys. Rev. D93 (2016) 012007

G. Vajente, LIGO-G1900400

# Questions and New Results

- *Blind* trial-and-error would be *impractically time (and money) consuming*.  
We implemented *extensive* simulations to provide guidelines to our experiments.
- Which materials are *more promising* to produce (binary) nanolayered films ?  
(Goals: noise reduction, cryo-compatibility)
- Which nanolayer *designs* are *more feasible* for a given material pair ?



Noise PSD (and Coating Loss Angle) Reduction Factor compared to Reference (Si/Ti::Ta, 5.32ppm@1064nm)							
	SiO <sub>2</sub>	Al <sub>2</sub> O <sub>3</sub>	HfO <sub>2</sub>	Ta <sub>2</sub> O <sub>5</sub>	ZrO <sub>2</sub>	Nb <sub>2</sub> O <sub>5</sub>	TiO <sub>2</sub>
SiO <sub>2</sub>	x	>1	>1	>1	>0.794	>0.792	>0.309
Al <sub>2</sub> O <sub>3</sub>		x	>1	>1	>0.833	>0.796	>0.352
HfO <sub>2</sub>			x	>1	>1	>0.849	>0.663
Ta <sub>2</sub> O <sub>5</sub>				x	>1	>0.802	>0.415
ZrO <sub>2</sub>					x	>0.791	>0.369
Nb <sub>2</sub> O <sub>5</sub>						x	>0.433
TiO <sub>2</sub>							x

[I. Pinto, LIGO-G1902307]

# HR Coating Modeling (QWL)

## Transmittance

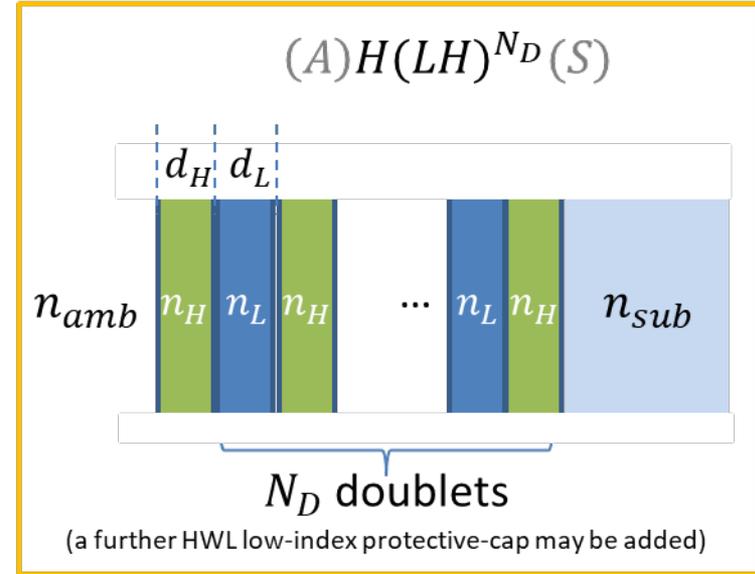
$$\Gamma = \frac{1 - \left(\frac{n_H}{n_L}\right)^{2N_D+2} \frac{n_L^2}{n_{amb}n_{sub}}}{1 + \left(\frac{n_H}{n_L}\right)^{2N_D+2} \frac{n_L^2}{n_{amb}n_{sub}}}, \quad \tau_P = 1 - |\Gamma|^2$$

index ratio  
(contrast)

number of doublets

$\cong n_L$ , typically

→ yields  $N_D$  from prescribed  $\tau_P$  and given contrast



## Coating Loss Angle (Thermal (Brownian) Noise PSD) can be written

$$\phi_c = \frac{1}{4\pi^{1/2}} \frac{\lambda_0 \phi_L}{w n_L} \left( \frac{Y_L}{Y_S} + \frac{Y_S}{Y_L} \right) \left[ N_d + \frac{n_L \phi_H \left( \frac{Y_H}{Y_S} + \frac{Y_S}{Y_H} \right)}{n_H \phi_L \left( \frac{Y_L}{Y_S} + \frac{Y_S}{Y_L} \right)} (1 + N_d) \right]$$

blows up linearly with  $N_d$

depends on choice of L-material only  
(usually the less noisy)

key quantity, depends on choice of H-material

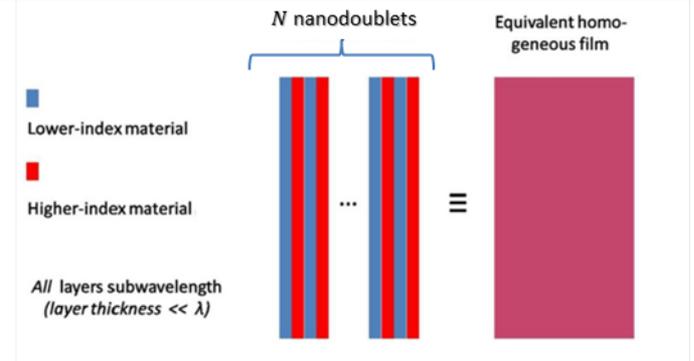
# Nanocomposite Modeling

$$n_{eff} = [r_H \tilde{n}_H^2 + (1 - r_H) \tilde{n}_L^2]^{1/2}$$

Drude's formula

*(normal incidence,  $\delta_{L,H} \ll \lambda$ )*

$$\phi_{eff} \left( \frac{Y_{eff}}{Y_s} + \frac{Y_s}{Y_{eff}} \right) = \left( \frac{\tilde{Y}_H}{Y_s} + \frac{Y_s}{\tilde{Y}_H} \right) r_H \tilde{\phi}_H + \left( \frac{\tilde{Y}_L}{Y_s} + \frac{Y_s}{\tilde{Y}_L} \right) (1 - r_H) \tilde{\phi}_L$$



Let :  $r_H = \frac{\delta_H}{\delta_L + \delta_H}$

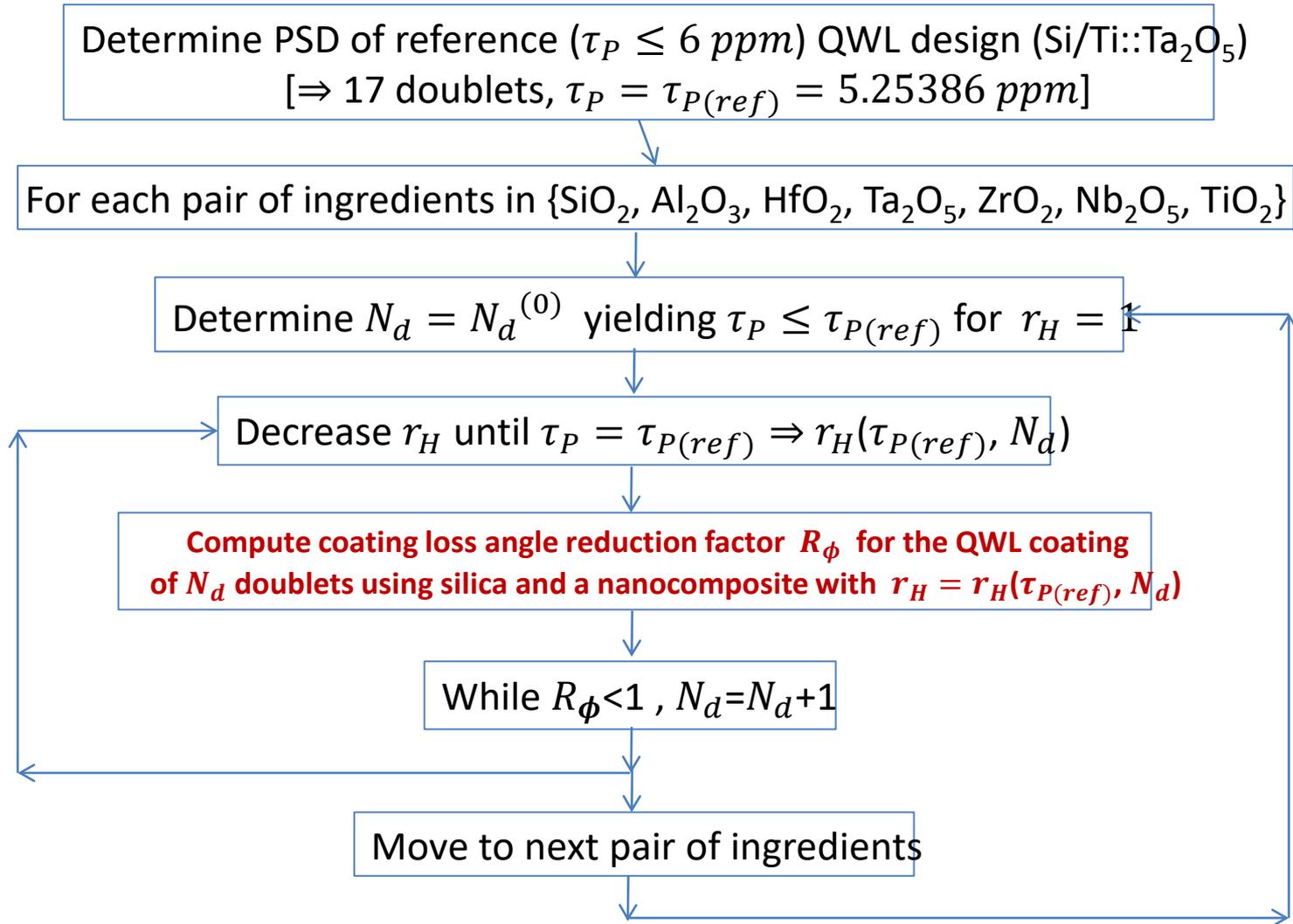
thickness fraction

total metric thicknesses of high ( $\delta_H$ ) and low ( $\delta_L$ ) index nanocomposite constituents

- Assigning the effective index  $n_{eff} \in (\tilde{n}_L, \tilde{n}_H)$  yields the ratio :  $\frac{\delta_L}{\delta_H} = \left( \frac{\tilde{n}_H^2 - n_{eff}^2}{n_{eff}^2 - \tilde{n}_L^2} \right)$  (1)
- Prescribing the optical thickness  $z$  enforces the condition :  $N(\delta_H + \delta_L) = z \frac{\lambda_0}{n_{eff}}$  (2)  
N being the total number of nanodoublets

**Eqs (1) and (2) yield an infinity of alternative and equivalent designs ( $\delta_L, \delta_H, N$ ). Larger N corresponding to thinner nano layers. Minimum and maximum allowed thicknesses are set by deposition machine and by chosen material (crystallization).**

# Simulation Algorithm



# SiO<sub>2</sub>/TiO<sub>2</sub> Nanocomposite HR Coatings

Sample output of simulation code : Silica-Titania

QWL HR Coating – Silica (L) / Silica-Titania nanolayered composite (H)				
#of doublets in Coating	Silica Fraction in nanocomposite	Effective index of nanocomposite	Coating power transmittance	Noise PSD Reduction
12	0.0882959	2.40581	5.25386	0.308983
13	0.188226	2.32031	5.25386	0.322875
14	0.269172	2.24867	5.25386	0.337020
15	0.335952	2.1878	5.25386	0.351363
16	0.391907	2.13547	5.25386	0.365862
17	0.439421	2.09	5.25386	0.380487

Code yields alternative nanocomposites, featuring

- different Silica/Titania (thickness) fractions
- different refractive index

to produce alternative HR coatings having the same reference transmittance, but

- different number of QWL doublets
- different noise PSD reduction factors

# Selecting a Nanocomposite Design

$r_L = 0.0882959$ ( $R_{PSD} = 0.30983$ )			$r_L = 0.188226$ ( $R_{PSD} = 0.322875$ )			$r_L = 0.269172$ ( $R_{PSD} = 0.33702$ )			$r_L = 0.335952$ ( $R_{PSD} = 0.351363$ )			$r_L = 0.391907$ ( $R_{PSD} = 0.365862$ )			$r_L = 0.439421$ ( $R_{PSD} = 0.3808437$ )		
$N$	$\delta_L[nm]$	$\delta_H[nm]$	$N$	$\delta_L[nm]$	$\delta_H[nm]$	$N$	$\delta_L[nm]$	$\delta_H[nm]$	$N$	$\delta_L[nm]$	$\delta_H[nm]$	$N$	$\delta_L[nm]$	$\delta_H[nm]$	$N$	$\delta_L[nm]$	$\delta_H[nm]$
7	1.39464	14.4005	18	1.19879	5.17009	28	1.13717	3.08754	27	1.51282	2.99026	25	1.95268	3.02983	23	2.43158	3.10202
8	1.22031	12.6004	19	1.13570	4.89798	29	1.09796	2.98108	28	1.45879	2.88347	26	1.87758	2.91330	24	2.33026	2.97277
9	1.08472	11.2004	20	1.07891	4.65308	30	1.06136	2.88171	29	1.40848	2.78404	27	1.80804	2.80540	25	2.23705	2.85386
10	0.97625	10.0803	21	1.02754	4.43151	31	1.02713	2.78875	30	1.36153	2.69123	28	1.74347	2.70521	26	2.15101	2.74409
			22	0.98083	4.23008	32	0.99503	2.70160	31	1.31761	2.60442	29	1.68335	2.61192	27	2.07135	2.64246
									32	1.27644	2.52303	30	1.62724	2.52486	28	1.99737	2.54809
									33	1.23776	2.44658	31	1.57474	2.44341	29	1.92849	2.46022
									34	1.20135	2.37462	32	1.52553	2.36705	30	1.86421	2.37821
									35	1.16703	2.30677	33	1.47930	2.29533	31	1.80407	2.30150
									36	1.13461	2.24270	34	1.43580	2.22782	32	1.74770	2.22958
									37	1.10395	2.18208	35	1.39477	2.16416	33	1.69474	2.16201
									38	1.07490	2.12466	36	1.35603	2.10405	34	1.64489	2.09842
									39	1.04733	2.07018	37	1.31938	2.04718	35	1.59789	2.03847
									40	1.02115	2.01843	38	1.28466	1.99331	36	1.55351	1.98184
									41	0.996245	1.96920	39	1.25172	1.94220	37	1.51152	1.92828
												40	1.22043	1.89364	38	1.47175	1.87754
												41	1.19066	1.84746	39	1.43401	1.82940
												42	1.16231	1.80347	40	1.39816	1.78366
												43	1.13528	1.76153	41	1.36406	1.74016
												44	1.10948	1.72149	42	1.33158	1.69872
												45	1.08482	1.68324	43	1.30061	1.65922
												46	1.06124	1.64665	44	1.27105	1.62151
												47	1.03866	1.61161	45	1.24281	1.58548
												48	1.01702	1.57804	46	1.21579	1.55101
												49	0.996267	1.54583	47	1.18992	1.51801
															48	1.16513	1.48638
															49	1.14135	1.45605
															50	1.11853	1.42693
															51	1.09659	1.39895
															52	1.07551	1.37205
															53	1.05521	1.34616
															54	1.03567	1.32123
															55	1.01684	1.29721
															56	0.99868	1.27404

Expected to crystallize before reaching  $T_{ann} = 650C$

Expected to remain amorphous at  $T_{ann} = 650C$

➔ Select a design featuring smallest  $R_{PSD}$  and minimum  $N$ , subject to  $\delta_L \geq 0.9nm$ , (feasible) and  $\delta_H \leq 2nm$  (remaining amorphous after 650C annealing)

# Best Nanocomposite Based HR Designs

$$(\delta_L, \delta_H)^{N_N} [\delta_{SiO_2}, (\delta_L, \delta_H)^{N_N}]^{N_D}$$

[I. Pinto, LIGO-G1902307]

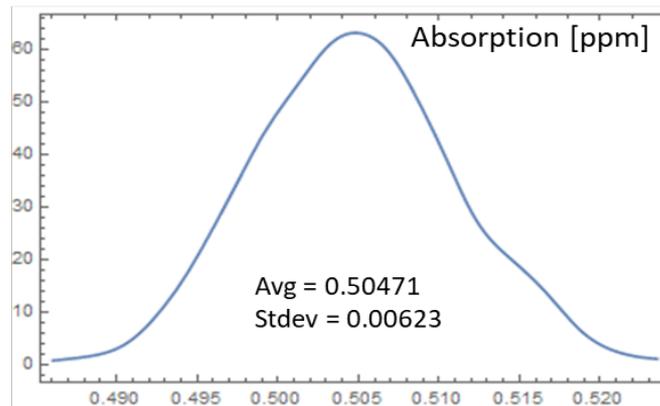
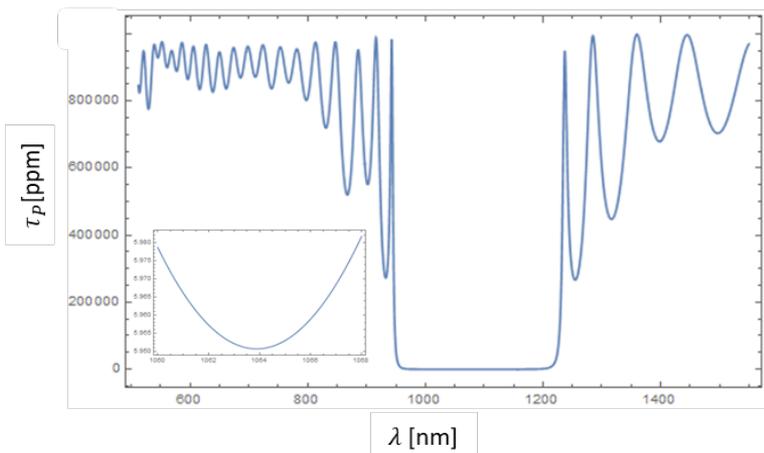
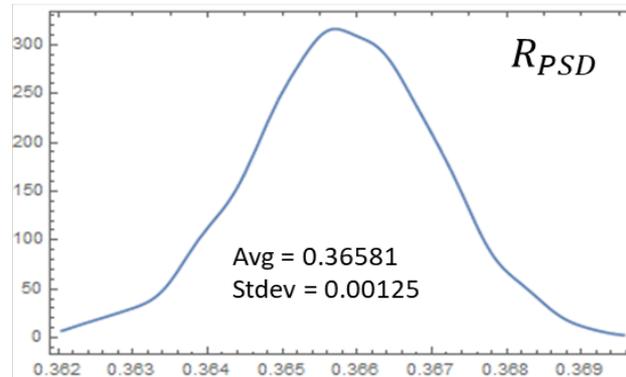
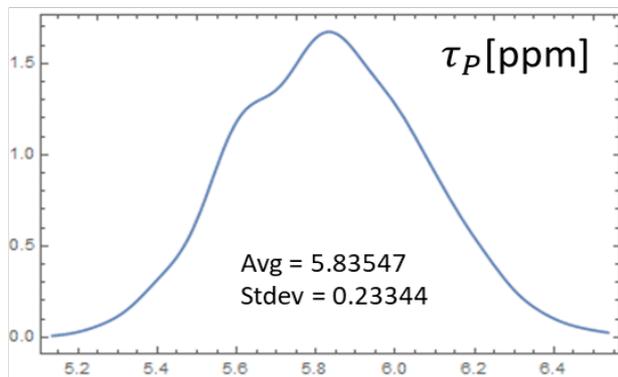
	Silica-Titania	Niobia-Titania	Zirconia-Titania	Alumina-Titania	Tantala-Titania
$\tau_p$ [ppm]	5.25386	5.25386	5.25386	5.25386	5.25386
$R_{PSD}$	0.36586	0.43352	0.464358	0.49998	0.57711
$N_D$	16	12	13	14	13
$N_N$	38	37	31	39	34
$\delta_L$ [nm]	1.28466	1.00106	1.71587	1.07652	1.39840
$\delta_H$ [nm]	1.99331	1.98720	1.98220	1.95661	1.97337
$\delta_{SiO_2}$ [nm]	183.499	183.499	183.499	183.499	183.499

➔ Reducing the noise PSD by a factor  $R_{PSD}$  yields an event rate boost by  $(R_{PSD})^{-3/2}$

# Robustness

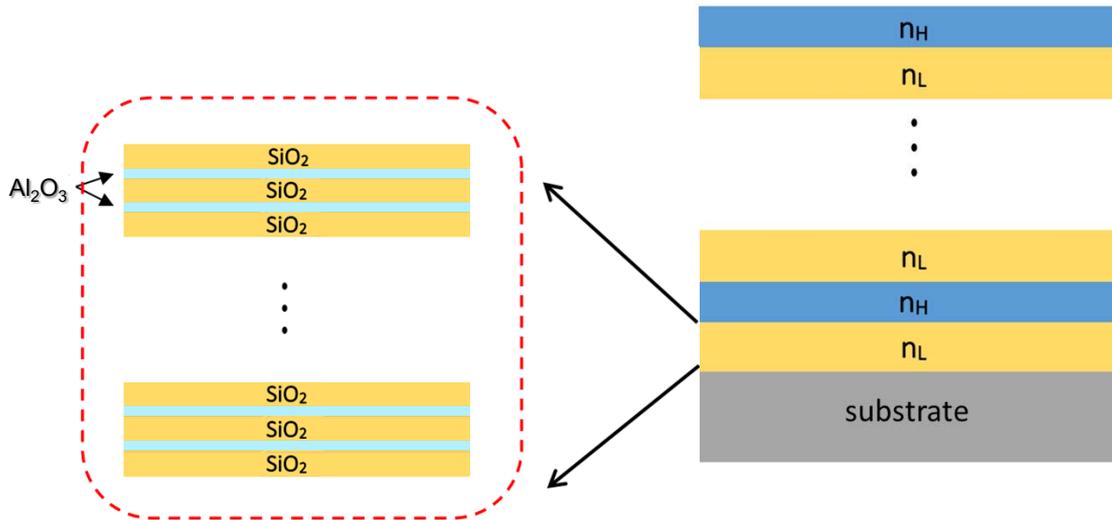
Assumption: i.i.d. Gaussian thickness errors with 0 avg. and .3nm std. deviation on each layer. 1000 trial-depositions.

	Silica-Titania
$\tau_P$ [ppm]	5.25386
$R_{PSD}$	0.36586
$N_D$	16
$N_N$	38
$\delta_L$ [nm]	1.28466
$\delta_H$ [nm]	1.99331
$\delta_{SiO_2}$ [nm]	183.499



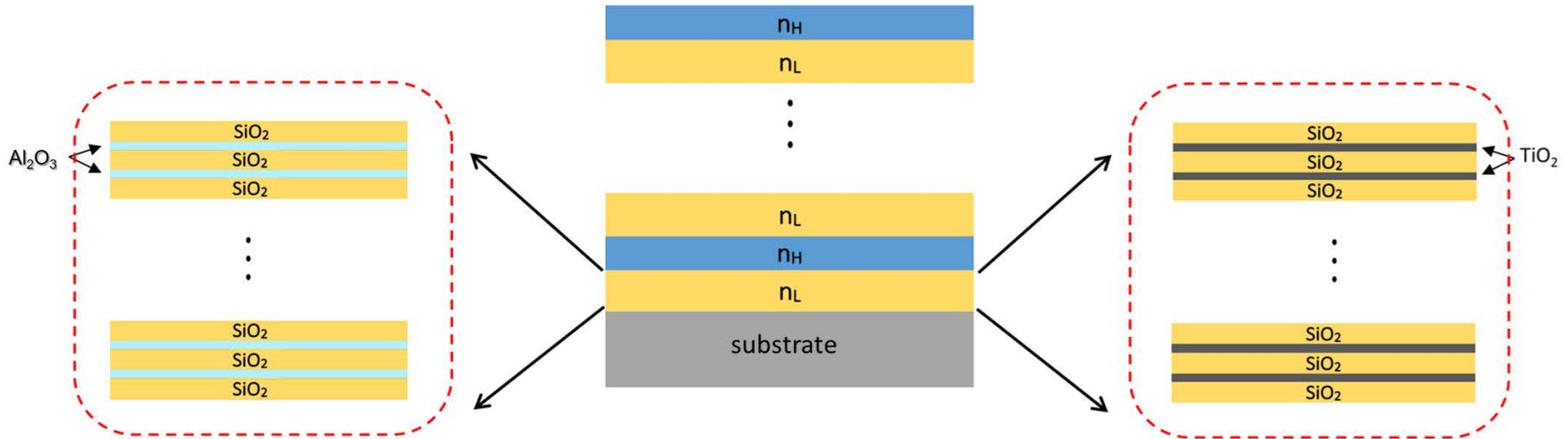
# Nanocomposite Based HR Coatings, contd.

Nanocomposite replacement for low-index coating layers



# Nanocomposite Based HR Coatings, contd.

Nanocomposite replacement for both low-index and high-index coating layers



# Conclusions

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- The nanolayered (binary) composites that may be used in place of the high index material in a QWL coating with the same  $\tau_p$  as the reference Si/Ti::Ta2O5 design, to obtain  $PSD \leq 0.5 PSD_{REF}$  are (best to worst)  
 $\{\text{SiO}_2, \text{TiO}_2\}$ ,  $\{\text{Nb}_2\text{O}_5, \text{TiO}_2\}$ ,  $\{\text{ZrO}_2, \text{TiO}_2\}$ ,  $\{\text{Al}_2\text{O}_3, \text{TiO}_2\}$ ,  $\{\text{Ta}_2\text{O}_5, \text{TiO}_2\}$
- The best (lowest refractive index, lowest mechanical loss) nanolayered (binary) composite that may be used in place of the low index material is  $\{\text{SiO}_2, \text{Al}_2\text{O}_3\}$ .
- For each material-pair it is possible to select a nanolayer design that should be free from crystallization upon annealing up to 650C, and feasible/easy to deposit (not too many nanolayers, not too thin).
- Extensive numerical simulations have been implemented to identify the above optimal designs. These are now pipelined for deposition and characterization in our Labs, in the frame of the VCR&D.
- Thickness optimization of the above coating designs may be added, and is expected to provide some extra noise reduction.

# Thank you so much for your attention

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ご清聴ありがとうございました



直接会えないことをおびします